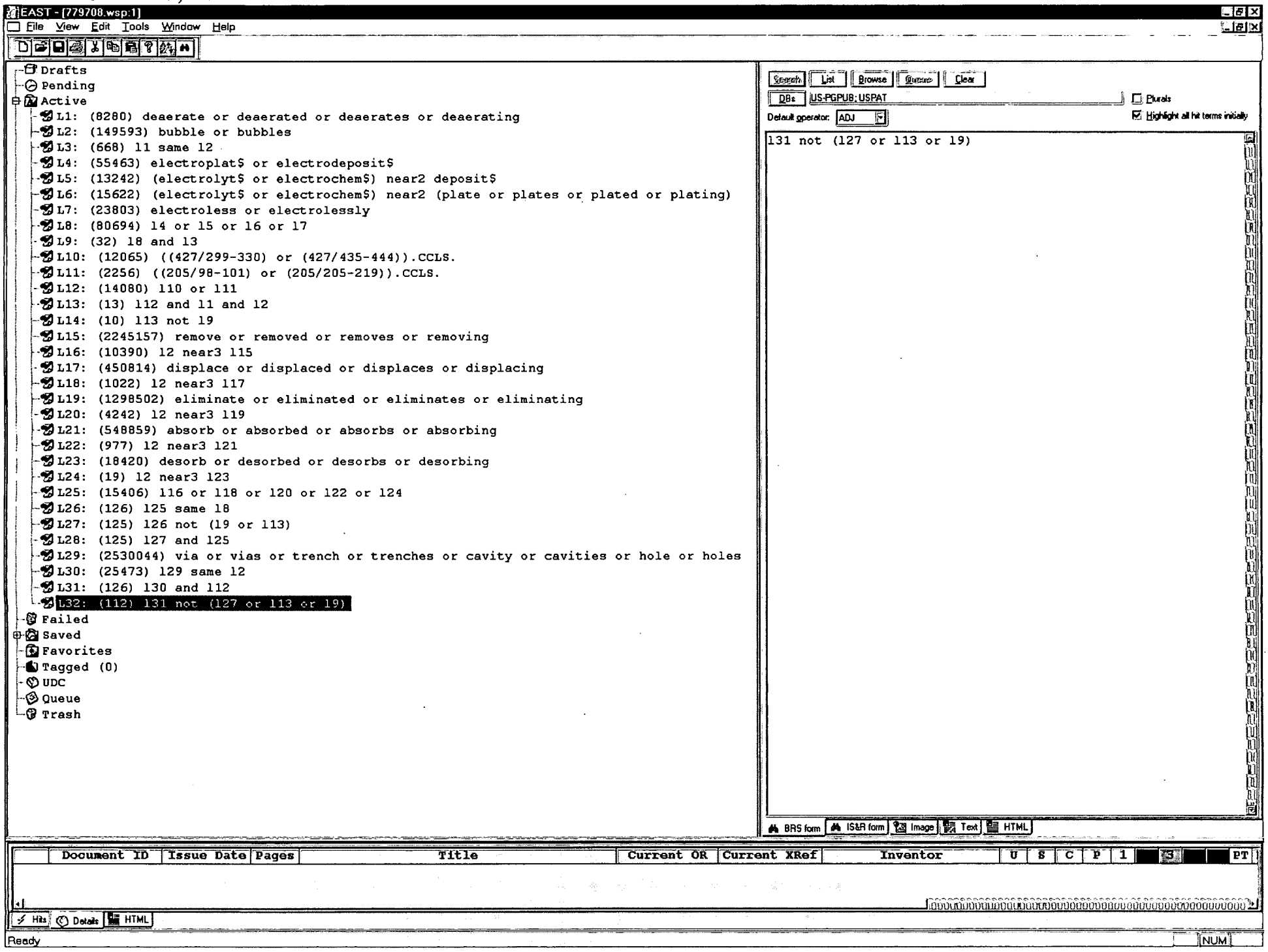
EAST - [779708.wsp:1]
File View Edit Tools Window Help
Drafts
Pending
Active
L1: (8280) deaerate or deaerated or deaerates or deaerating
L2: (149593) bubble or bubbles
L3: (668) l1 same l2
L4: (55463) electroplat$ or electrodeposit$
L5: (13242) (electrolyt$ or electrochem$) near2 deposit$
L6: (15622) (electrolyt$ or electrochem$) near2 (plate or plates or plated or plating)
L7: (23803) electroless or electrolessly
L8: (80694) l4 or l5 or l6 or l7
L9: (32) l8 and l3
L10: (12065) ((427/299-330) or (427/435-444)).CCLS.
L11: (2256) ((205/98-101) or (205/205-219)).CCLS.
L12: (14080) l10 or l11
L13: (13) l12 and l1 and l2
L14: (10) l13 not l9
L15: (2245157) remove or removed or removes or removing
L16: (10390) l2 near3 l15
L17: (450814) displace or displaced or displaces or displacing
L18: (1022) l2 near3 l17
L19: (1298502) eliminate or eliminated or eliminates or eliminating
L20: (4242) l2 near3 l19
L21: (548859) absorb or absorbed or absorbs or absorbing
L22: (977) l2 near3 l21
L23: (18420) desorb or desorbed or desorbs or desorbing
L24: (19) l2 near3 l23
L25: (15406) l16 or l18 or l20 or l22 or l24
L26: (126) l25 same l8
L27: (125) l26 not (l9 or l13)
L28: (125) l27 and l25
L29: (2530044) via or vias or trench or trenches or cavity or cavities or hole or holes
L30: (25473) l29 same l2
L31: (126) l30 and l12
L32: (112) l31 not (l27 or l13 or l9)
Failed
Saved
Favorites
Tagged (0)
UDC
Queue
Trash
Search List Browse Image Clear
DBs US-PGPUB; USPAT
Plurals
Default operator: ADJ
Highlight all hit terms initially
131 not (127 or 113 or 19)
BRS form IS&R form Image Text HTML
Document ID Issue Date Pages Title Current OR Current XRef Inventor U S C P 1 3 PT
Hits Details HTML
Ready
NUM

EAST - [Untitled1:1]

File View Edit Tools Window Help

- Drafts
- Pending
- Active
  - L1: (6899) deaerate or deaerated or deaerates or deaerating
  - L2: (94344) bubble or bubbles
  - L3: (48699) electroplat$ or electrodeposit$
  - L4: (5624) (electrolyt$ or electrochem$) near2 deposit$
  - L5: (13851) (electrolyt$ or electrochem$) near2 (plate or plates or plated or plating)
  - L6: (18821) electroless or electrolessly
  - L7: (80730) 13 or 14 or 15 or 16
  - L8: (4) l1 and l2 and l7
- Failed
- Saved
- Favorites
- Tagged (0)
- UDC
- Queue
- Trash

Search | Edit | Browse | Clear

DBs | EPO; JPO; DERWENT; IBM_TDB | Plurals

Default operator: ADJ | Highlight all hit terms initially

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l1 and l2 and l7
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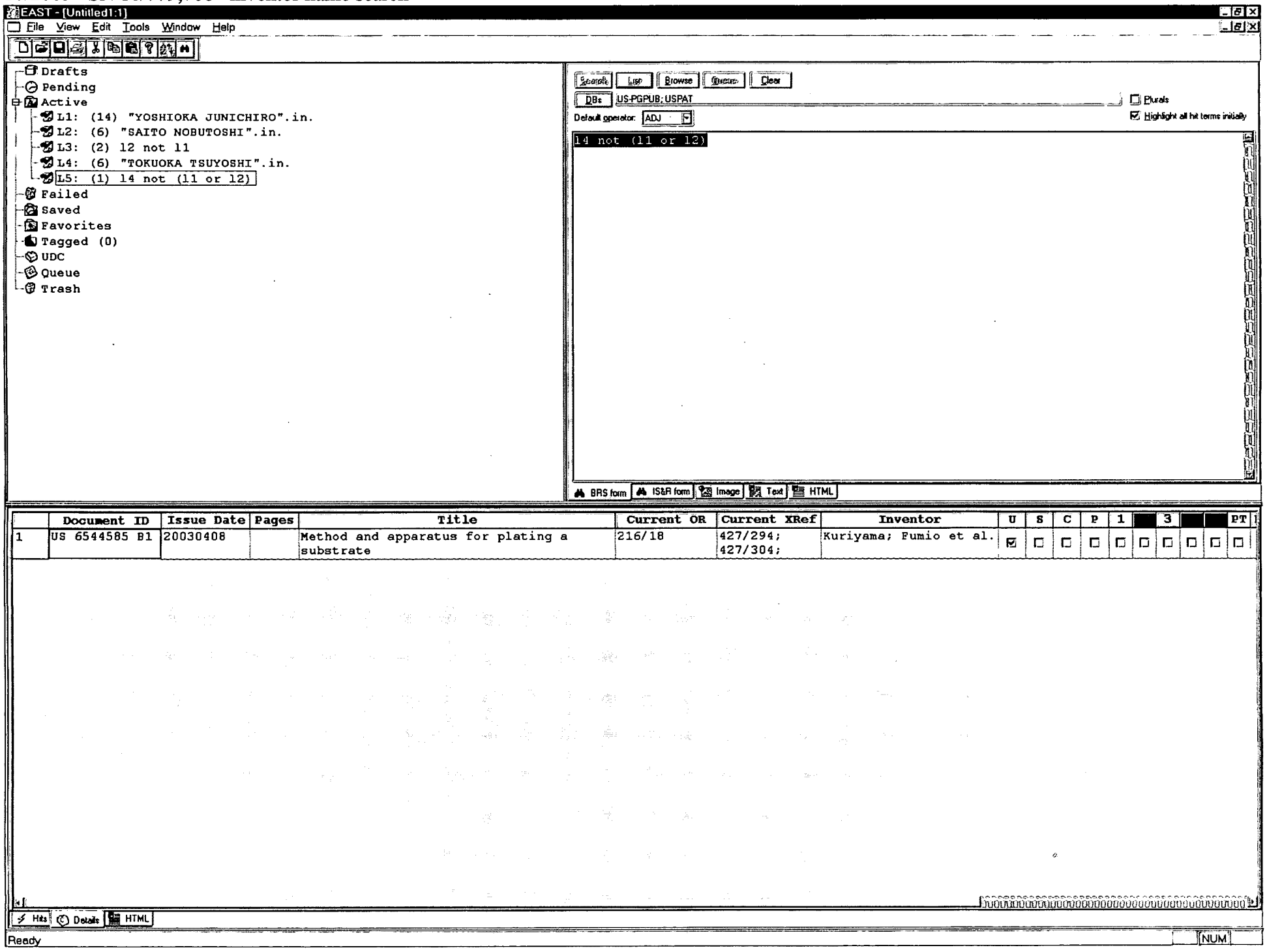
BRS form | IS&R form | Image | Text | HTML

	Document ID	Issue Date	Pages	Title	Current OR	Current XRef	Inventor	U	S	C	P	1		3			PT
1	JP 2003201600 A	20030718	9	PLATING APPARATUS, AND SEMICONDUCTOR DEVICE MANUFACTURING METHOD			OKASE, WATARU et al.	☑	☐	☐	☐	☐	☐	☐	☐	☐	☐
2	JP 02129393 A	19900517		PRODUCTION OF SEMICONDUCTOR DEVICE			OOSAKO, NAGISA	☑	☐	☐	☐	☐	☐	☐	☐	☐	☐
3	EP 327887 A1	19890816		A fuel cell, electrode for the cell and method of preparation thereof.			OKADA, HIDEO et al.	☑	☐	☐	☐	☐	☐	☐	☐	☐	☐
4	JP 04105058 A	19920407		Forming sensitive film for electrochemical sensor - where soln.				☑	☐	☐	☐	☐	☐	☐	☐	☐	☐

Hits | Details | HTML

Ready NUM

10/2005 SN 10/779,708 inventor name search